



AMENDMENT TRANSMITTAL LETTER

Docket No.
M4065.0353/P353-A

Application No.
09/982,954

Filing Date
October 22, 2001

Examiner
Karla A. Moore

Art Unit
1763

Applicant(s): Gurtej Sandhu, et al.

Invention: ATOMIC LAYER DOPING APPARATUS AND METHOD

TO THE COMMISSIONER FOR PATENTS

Transmitted herewith is an amendment in the above-identified application.

The fee has been calculated and is transmitted as shown below.

CLAIMS AS AMENDED

	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate	
Total Claims	19	- 20 =		x	0.00
Independent Claims	3	- 3 =		x	0.00
Multiple Dependent Claims (check if applicable) <input type="checkbox"/>					
Other fee (please specify):					
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT:					0.00

☒ Large Entity

☐ Small Entity

☒ No additional fee is required for this amendment.

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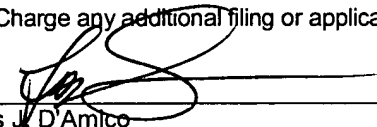
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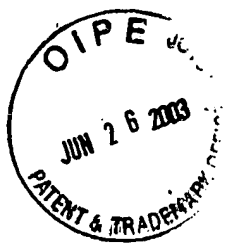
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Thomas J. D'Amico
Attorney Reg. No.: 28,371
DICKSTEIN SHAPIRO MORIN & OSHINSKY LLP
2101 L Street NW
Washington, DC 20037-1526
(202) 828-2232

Dated: June 26, 2003



Docket No.: M4065.0353/P353-A
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of:
Gurtej Sandhu et al.

Application No.: 09/982,954

Group Art Unit: 1763

Filed: October 22, 2001

Examiner: Karla A. Moore

For: ATOMIC LAYER DOPING APPARATUS
AND METHOD

Corr

#121

9/9/03

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AMENDMENT

Mail stop: Amendment
Commissioner for Patents
P.O. Box 1450
Washington, DC 22313-1450

Dear Sir:

This paper is further to Applicants' response filed May 22, 2003. Please amend the above-identified U.S. patent application as follows:

In the Claims:

Please rewrite claim 1 as follows:

1. (amended) An atomic layer doping apparatus comprising:

a first atomic layer doping region for depositing a first dopant species on a first substrate as an atomic monolayer;